

## Supporting Information

### Supercapattery-driven electrolyzer both empowered by the same superb electrocatalyst

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### Experimental section

**Synthesis of  $\text{CuCo}_2\text{O}_4$  nanoneedles:** Typically,  $\text{CoCl}_2 \cdot 6\text{H}_2\text{O}$  (2 mM),  $\text{CuCl}_2 \cdot 6\text{H}_2\text{O}$  (1 mM), and urea (20 mM) were dissolved in 40 mL of deionized (DI) water under stirring. Cleaned NF was immersed in the as-prepared reaction mixture. The above solution was then transferred into a 100 mL Teflon autoclave and maintained at 120 °C for 10 h. Finally, the resulting  $\text{CuCo}_2\text{O}_4$ -coated NF was annealed at 300 °C under a  $\text{N}_2$  atmosphere. The obtained  $\text{CuCo}_2\text{O}_4$  was rinsed with DI water and ethanol and then dried at 70 °C for further use.

**Synthesis of the Encapsulated  $\text{CuCo}_2\text{O}_4/\text{MoNi}$ :** Typically, 1 mmol  $\text{Ni}(\text{NO}_3)_2 \cdot 6\text{H}_2\text{O}$ , 1 mmol  $\text{Na}_2\text{MoO}_4 \cdot 2\text{H}_2\text{O}$ , and 7.5 mmol urea were mixed in 40 mL of DI water under stirring. Then, a piece of NF coated with the  $\text{CuCo}_2\text{O}_4$  was then immersed in the reaction mixture. Then, it was

transferred to a 100 mL Teflon-lined autoclave and kept at 150°C for 3 h. Then, the product was washed with DI water and ethanol and dried at 60°C. The CuCo<sub>2</sub>O<sub>4</sub>/MoNi were obtained by annealing the above prepared sample in a H<sub>2</sub>/Ar (5:95) atmosphere at 500 °C for 2 h.

***Preparation of NiO encapsulated CuCo<sub>2</sub>O<sub>4</sub>/MoNi:*** Thin NiO layers were deposited over the CuCo<sub>2</sub>O<sub>4</sub>/MoNi architecture on NF via 420 deposition cycles using a laboratory-built flow-type ALD reactor.<sup>1</sup> During deposition, the temperature was maintained at 175 °C.

### ***Characterizations***

XRD data of the samples were recorded by a Rigaku X-ray diffractometer X-ray diffractometer with CuK $\alpha$  radiation. The morphologies and microstructures of the samples were investigated by FE-SEM (JEOL JSM-7500F) and TEM (TECNAI G2 F20 TEM system). XPS was performed on an ESCALAB-MKII, VG Scientific Co. system. The Brunauer-Emmett-Teller (BET, ASAP2010, Micromeritics) was done to measure surface area of the prepared products.

### **Water splitting measurements**

Electrocatalytic properties of the as-prepared samples on the NF were carried out in a three-electrode cell, where SCE and Pt foil were employed as the reference and counter, electrodes using the electrochemical workstation (WonATech WBCS30000), respectively. Additionally, 5 mg of Pt/C (or RuO<sub>2</sub>) and 10  $\mu$ L of Nafion were dispersed in 1 mL of a water/alcohol mixture solution (3:1) using ultrasonication to prepare an ink. Finally, 50  $\mu$ L of the catalyst ink was coated on NF and dried at 60°C. Additionally, LSV measurements were performed at 2 mV s<sup>-1</sup> for the OER and HER in a 1 M KOH. The EIS measurement were conducted using a Parstat 3000 workstation (0.01 Hz to 100 kHz with a 10 mV amplitude). A gas

chromatography (074-594-P1E Micro GC Fusion, INFICON) was used to analyze the amount of the gaseous products. All potentials were calibrated to the RHE using Eq. 1;  $\eta$  was obtained using Eq. 2 and the Tafel slope was obtained using Eq. 3:

$$E_{\text{RHE}} = E_{\text{SCE}} + 0.059\text{pH} + 0.247, \quad (1)$$

$$\eta = E_{\text{RHE}} - 1.23, \quad (2)$$

$$\eta = b \log j + a. \quad (3)$$

### Supercapattery measurements

The electrochemical capacitive properties of the as-prepared heterostructure electrodes were carried out in 2 M KOH aqueous solution using a three-electrode cell. The as-fabricated materials on NF, Pt foil and SCE were employed as the working, counter and reference electrodes, respectively. The mass loading of the NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi/MoO<sub>2</sub> heterostructure and AC were measured to be 4.3 and 5.4 mg cm<sup>-2</sup>, respectively. In the supercapattery cell, the NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi/MoO<sub>2</sub> heterostructure electrode used as the cathode and AC as the anode with 2M KOH/PVA gel as the electrolyte.

Specific capacitance ( $C_s$ , F g<sup>-1</sup>) and specific capacity ( $C_m$ , C g<sup>-1</sup>) from GCD test was calculated by using the relation,<sup>2,3</sup>

$$C_s = \frac{2i/V dt}{m (V_f - V_i)^2} \quad (4)$$

$$C_m = C_s \times \Delta V \quad (5)$$

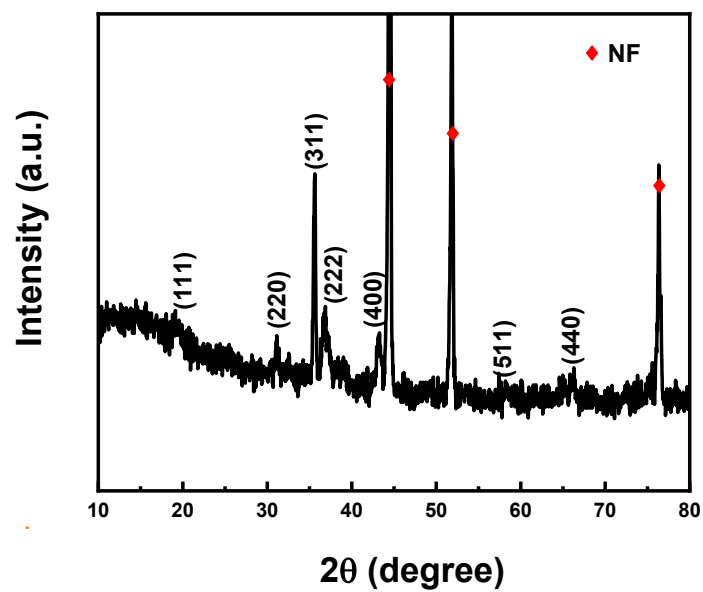
where,  $m$  (g),  $i$  (A),  $(V_f - V_i)$ , and  $\int V dt$  are the mass of the active materials coated on NF, applied current, functional potential frame, and the integral area of discharge curve, respectively.

The energy density ( $E$ ) and power density ( $P$ ) of the supercapattery were calculated according to the following formulas:

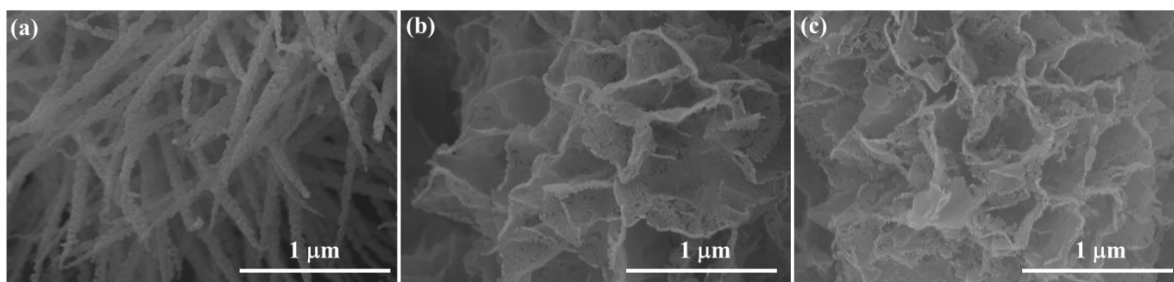
$$E = \frac{I \int V dt}{3.6} \quad (6)$$

$$P = \frac{3600 \times E}{t} \quad (7)$$

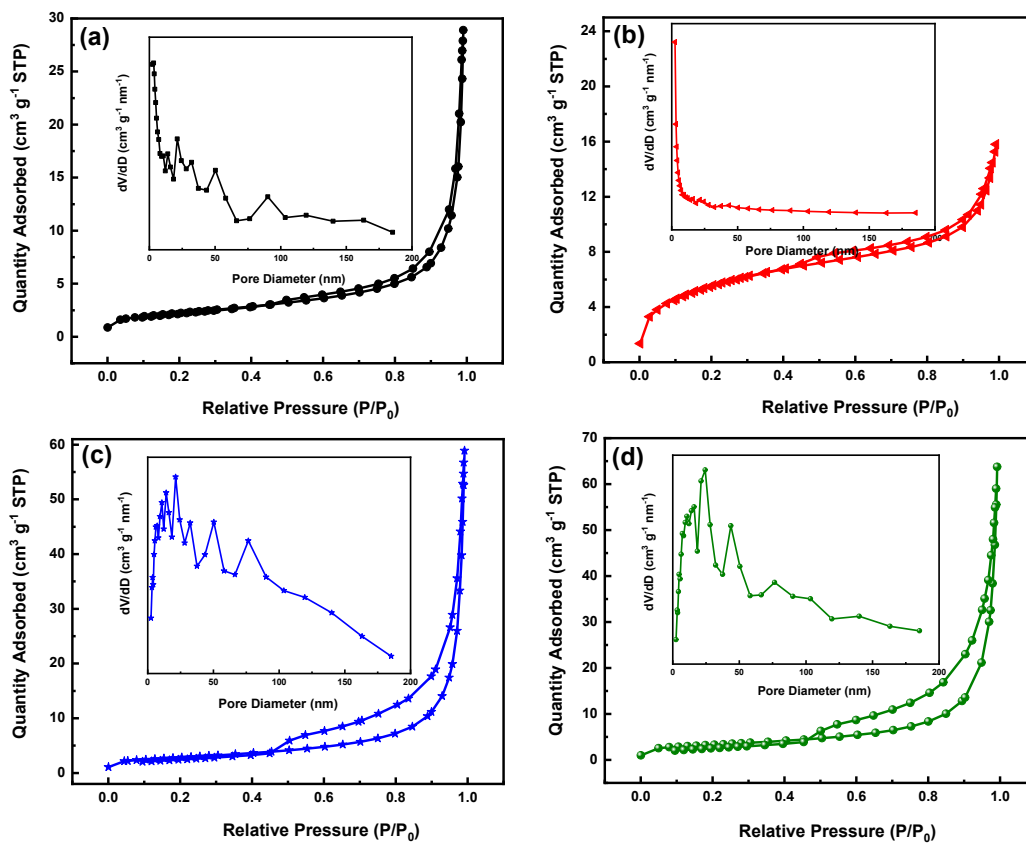
Where  $I$  (A g<sup>-1</sup>) and  $t$  (s) are the current density, and discharge time of the supercapattery cell, respectively.



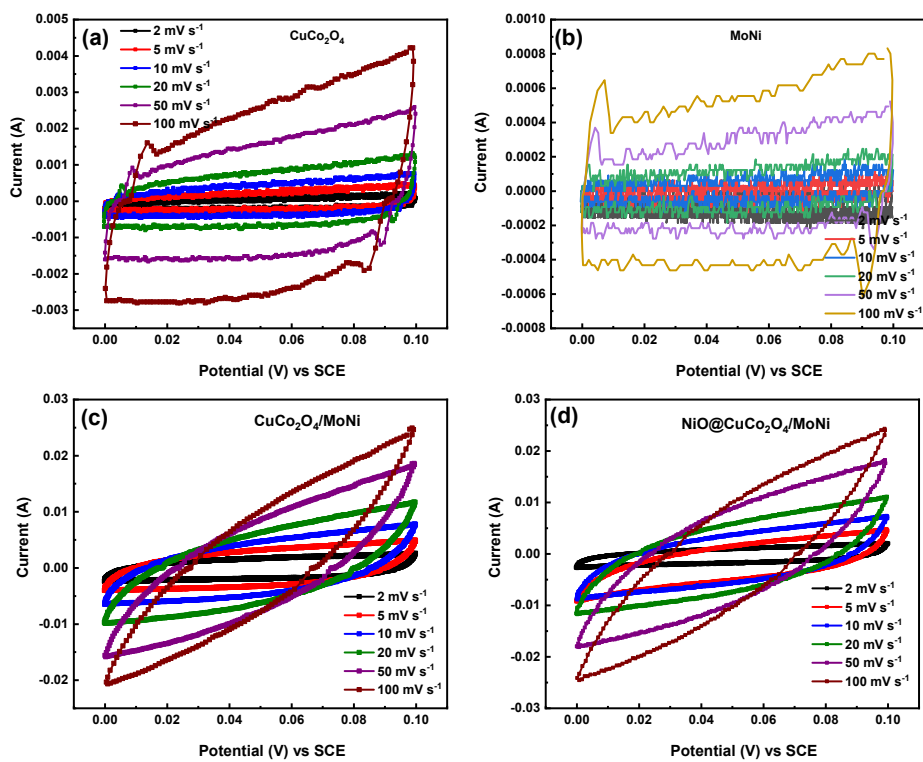
**Figure S1.** XRD pattern of the  $\text{CuCo}_2\text{O}_4$  nano-needle from the NF substrate.



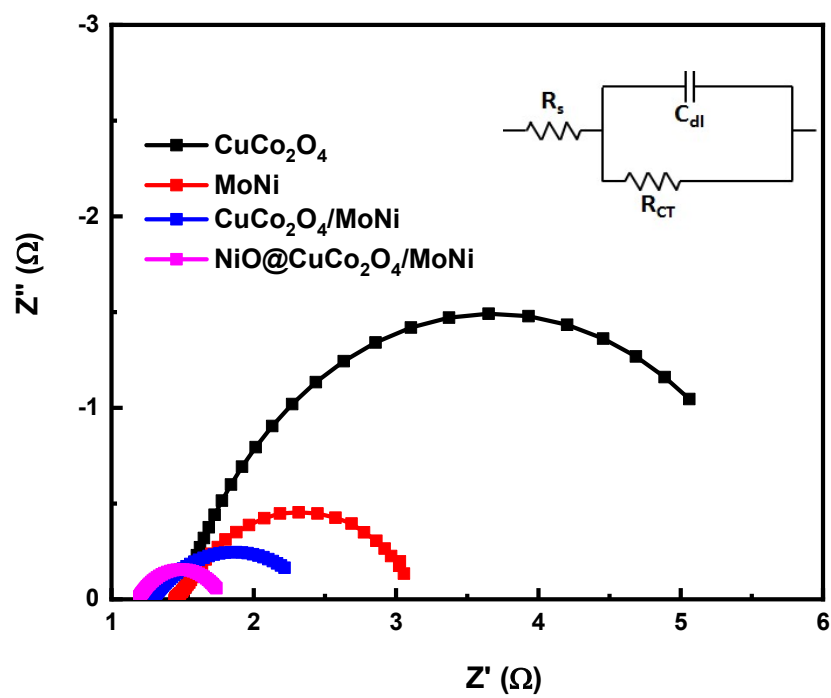
**Figure S2.** FE-SEM images of a)  $\text{CuCo}_2\text{O}_4$ , b) MoNi, and c)  $\text{CuCo}_2\text{O}_4/\text{MoNi}$ .



**Figure S3.**  $N_2$  adsorption-desorption isotherms of a)  $\text{CuCo}_2\text{O}_4$ , b)  $\text{MoNi}$ , c)  $\text{CuCo}_2\text{O}_4/\text{MoNi}$  and d)  $\text{NiO}@CuCo_2O_4/\text{MoNi}$  heteronanostructure. Inset shows corresponding pore size distribution profiles.

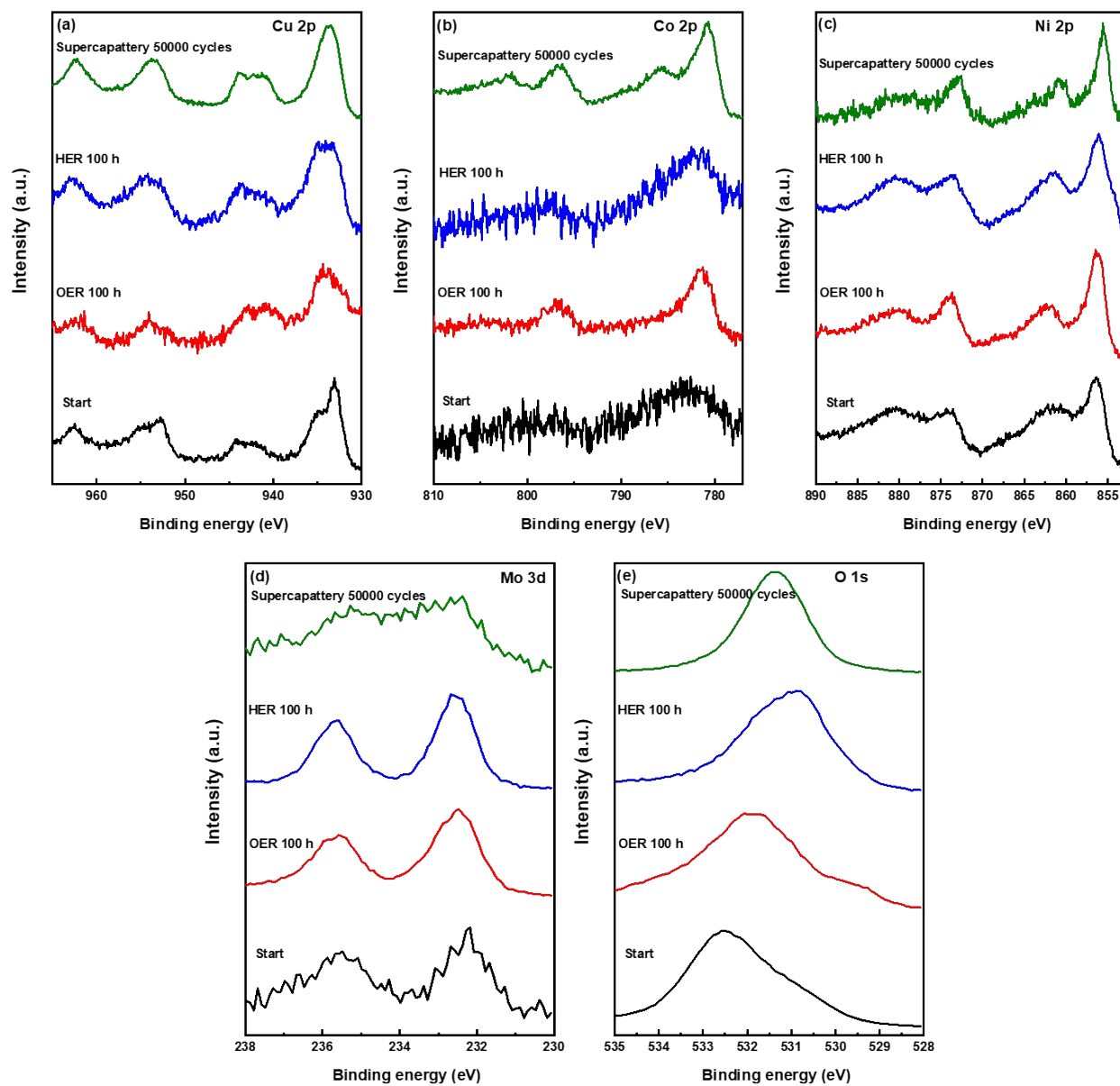


**Figure S4.** CV profiles of a)  $\text{CuCo}_2\text{O}_4$ , b)  $\text{MoNi}$ , c)  $\text{CuCo}_2\text{O}_4/\text{MoNi}$  and d)  $\text{NiO}@\text{CuCo}_2\text{O}_4/\text{MoNi}$  at different sweep rates in 1 M KOH.

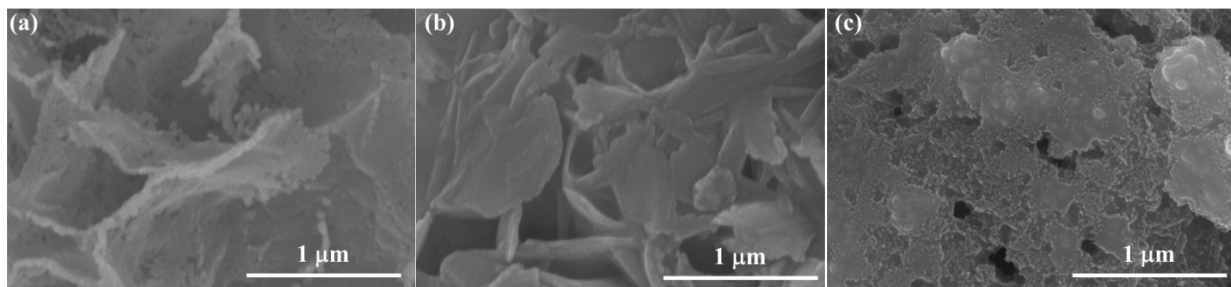


**Figure S5.** Nyquist plots for the as-prepared samples at -0.2 V. The inset shows the electrochemical equivalent circuit.

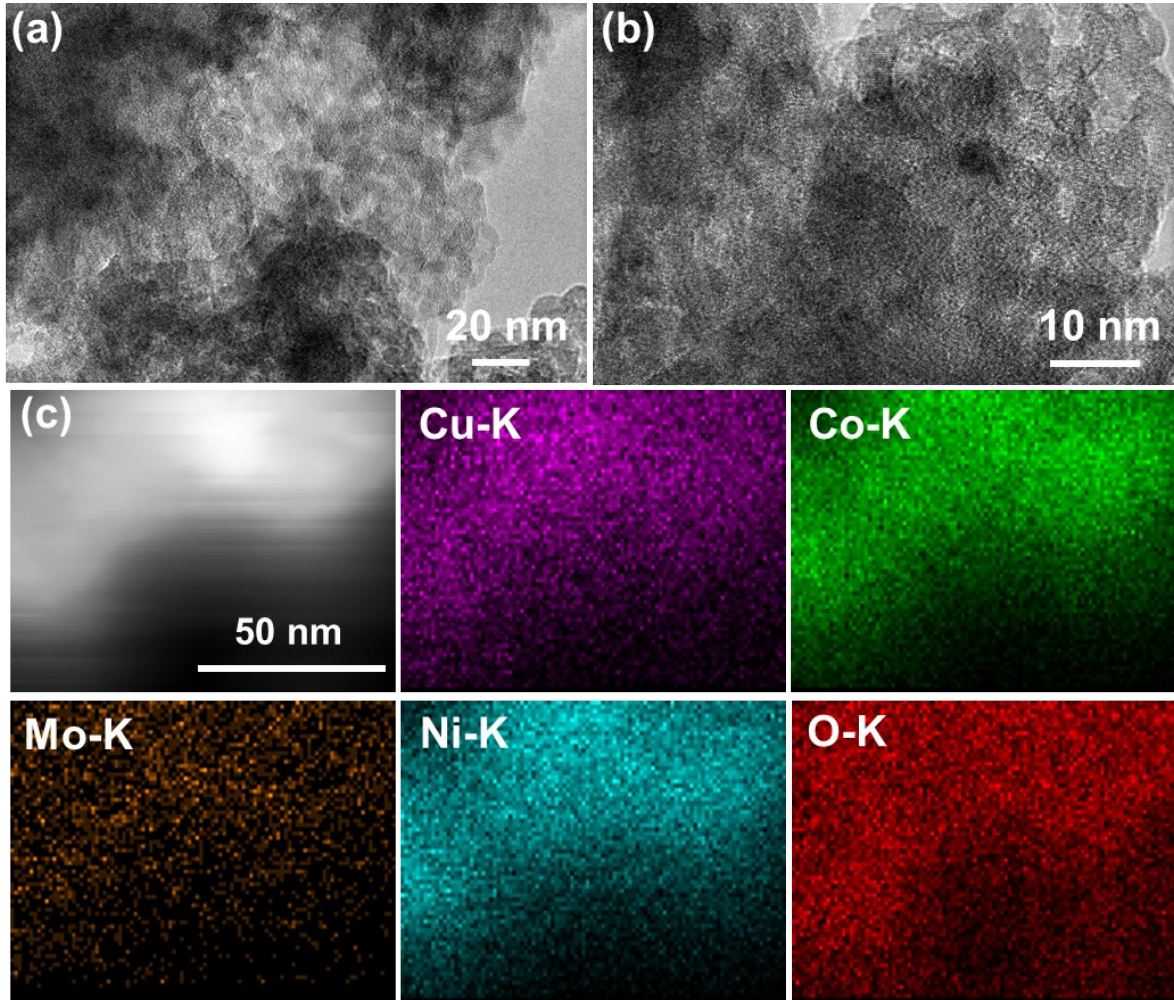




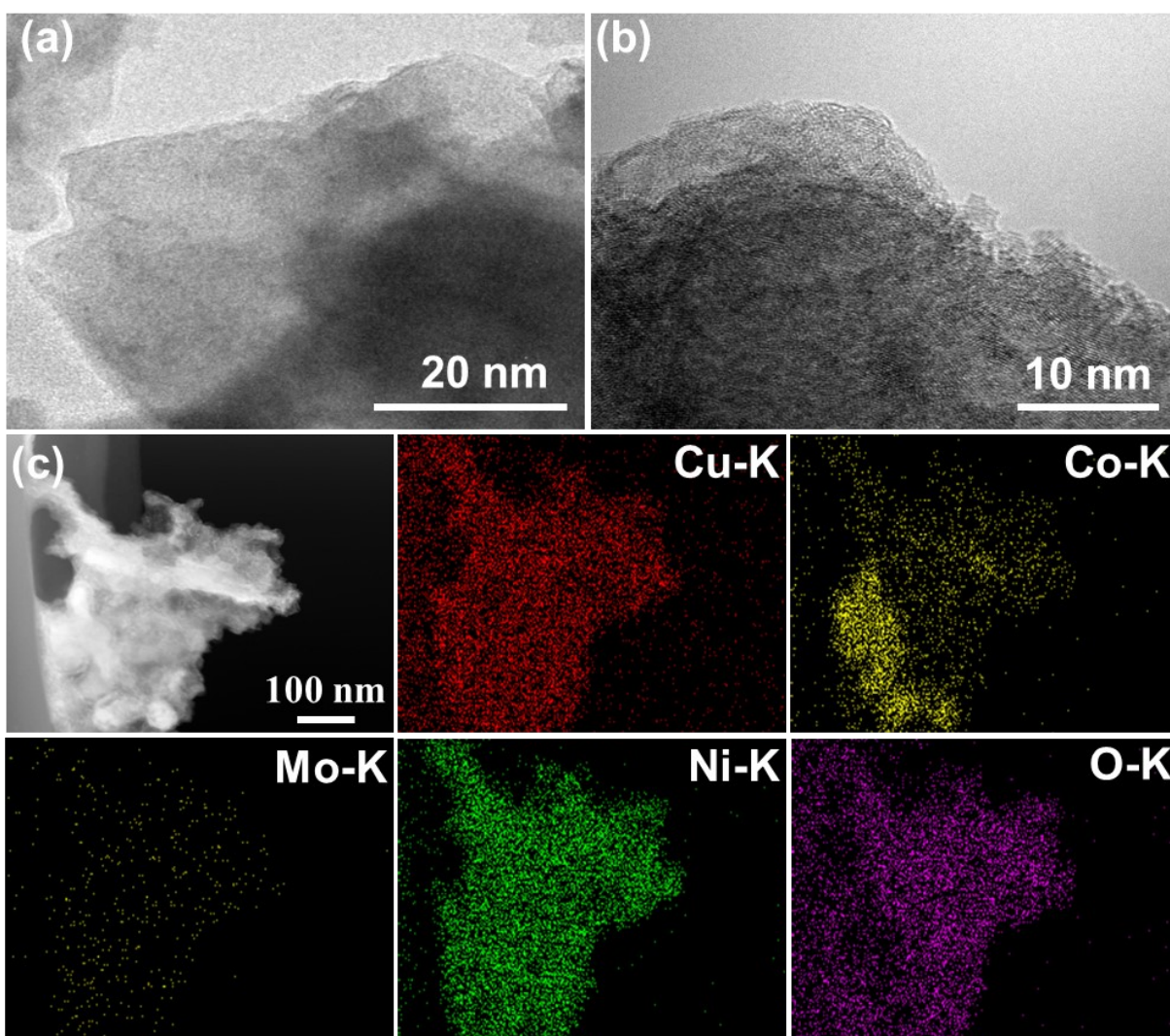
**Figure S6.** XPS spectra of a) Cu 2p, b) Co 2p, c) Ni 2p, d) Mo 3d and e) O 1s for NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure before and after OER, HER, and supercapattery test.



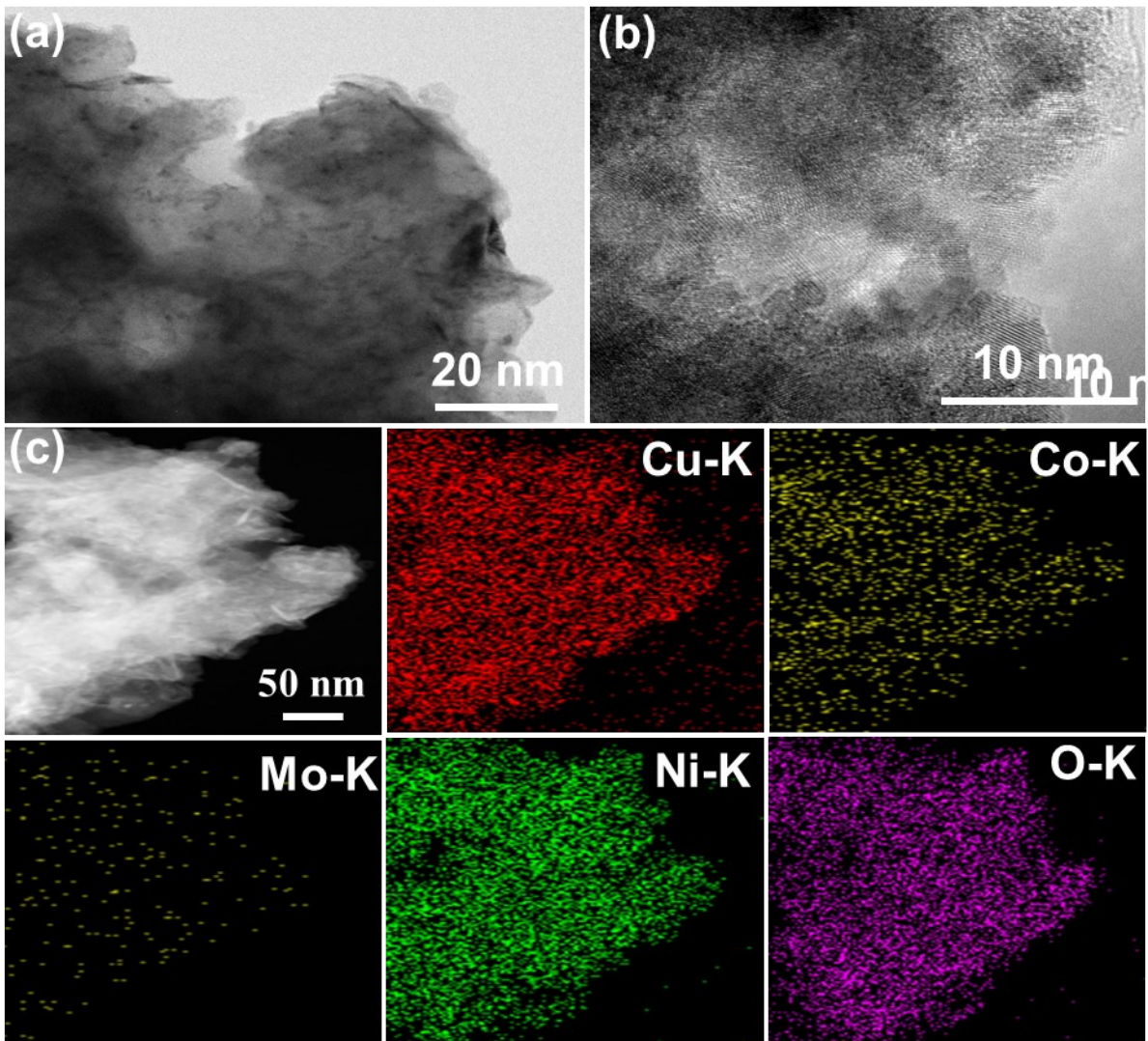
**Figure S7.** FE-SEM images of the NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure after a) OER, b) HER, and c) supercapattery test.



**Figure S8.** HR-TEM images of the NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure after a, b) HER test and c) the corresponding elemental mapping of NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure.



**Figure S9.** HR-TEM images of the NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure after a, b) OER test and c) the corresponding elemental mapping of NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure.



**Figure S10.** HR-TEM images of the NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure after a, b) 50000 cycling test and c) the corresponding elemental mapping of NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure.

**Table S1.** Comparison of HER performances of NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure with other reported electrocatalysts.

Catalyst	Electrolyte	Overpotential at 50 mA cm <sup>-2</sup> (mV)	Tafel slope (mV dec <sup>-1</sup> )	Ref.
NiO@CuCo <sub>2</sub> O <sub>4</sub> /MoNi heterostructure	1 M KOH	61.0	44.2	This work
NiMoO <sub>x</sub> /NiMoS	1 M KOH	~63	-	4
MoS <sub>2</sub> /Ni <sub>3</sub> S <sub>2</sub>	1 M KOH	~175	-	5
NiCo <sub>2</sub> O <sub>4</sub> @NiMoO <sub>4</sub>	1 M KOH	300	94.0	6
NiCo <sub>2</sub> O <sub>4</sub> @Ni <sub>0.796</sub> CoLDH	1 M KOH	115	56.4	7
FeOOH/NiCo <sub>2</sub> O <sub>4</sub>	1 M KOH	146	41.3	8
Ni(OH) <sub>2</sub> @CuS	1 M KOH	95	42.0	9
H-Fe-CoMoS	1 M KOH	138	98.0	10
Co/Co <sub>2</sub> Mo <sub>3</sub> O <sub>8</sub>	1 M KOH	~110	-	11
NiFe-LDH/NiCo <sub>2</sub> O <sub>4</sub>	1 M KOH	192	59.0	12
Ni <sub>3</sub> N/Pt	1 M KOH	83	-	13
Mo-NiCoP	1 M KOH	121	-	14
NiCo <sub>2</sub> O <sub>4</sub> @CoMoO <sub>4</sub>	1 M KOH	121	77.0	15

**Table S2.** Comparison of OER performances of NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure with other reported electrocatalysts.

Catalyst	Electrolyte	Overpotential at 100 mA cm <sup>-2</sup> (mV)	Tafel slope (mV dec <sup>-1</sup> )	Ref.
NiO@CuCo <sub>2</sub> O <sub>4</sub> /MoNi heterostructure	1 M KOH	370	69.1	This work
NiCo <sub>2</sub> O <sub>4</sub> @CoMoO <sub>4</sub>	1 M KOH	~490	-	15
NiCo <sub>2</sub> O <sub>4</sub> @NiMoO <sub>4</sub>	1 M KOH	~420	-	16
Fe <sub>2</sub> O <sub>3</sub> @CuO NTs	1 M KOH	~380	-	17
Ni@Co-Ni-P	1 M KOH	380	65	18
Co <sub>3</sub> O <sub>4</sub> /NiCo <sub>2</sub> O <sub>4</sub>	1 M KOH	495	88	19
NiCoFe phosphate NSs-C	1 M KOH	~350	-	20
Ni <sub>2</sub> P@NF-6	1 M KOH	590	297	21
p-Cu <sub>1-x</sub> NNi <sub>3-y</sub> /FeNiCu	1 M KOH	~350	-	22
NiCoP NWAs/NF	1 M KOH	~320	-	23

**Table S3.** Comparison of water splitting performance of NiO@CuCo<sub>2</sub>O<sub>4</sub>/MoNi heterostructure with other reported bi-functional electrocatalysts based on transition metals.

Catalyst	Electrolyte	Voltage (V)	Ref.
NiO@CuCo <sub>2</sub> O <sub>4</sub> /MoNi heterostructure	1 M KOH	1.54 V @ 10 mA cm <sup>-2</sup>	This work
E-Mo-NiCoP	1 M KOH	1.61 V @ 10 mA cm <sup>-2</sup>	14
FeCo <sub>2</sub> S <sub>4</sub>	1 M KOH	1.56 V @ 10 mA cm <sup>-2</sup>	24
NiSe/Ni <sub>3</sub> Se <sub>2</sub>	1 M KOH	1.6 V @ 10 mA cm <sup>-2</sup>	25
NiS-Ni <sub>2</sub> P <sub>2</sub> S <sub>6</sub>	1 M KOH	1.64 V @ 10 mA cm <sup>-2</sup>	26
NiFe/NiCo <sub>2</sub> O <sub>4</sub>	1 M KOH	1.67 V @ 10 mA cm <sup>-2</sup>	27
NiCo <sub>2</sub> O <sub>4</sub> /NiCoP	1 M KOH	1.66 V @ 10 mA cm <sup>-2</sup>	28
Ni <sub>3</sub> S <sub>2</sub>	1 M KOH	1.57 V @ 10 mA cm <sup>-2</sup>	29
Ni/NiO	1 M KOH	1.71 V @ 10 mA cm <sup>-2</sup>	30
Co <sub>x</sub> PO <sub>4</sub> /CoP	1 M KOH	1.91 V @ 10 mA cm <sup>-2</sup>	31
Co <sub>9</sub> S <sub>8</sub> -CoSe <sub>2</sub>	1 M KOH	1.66 V @ 10 mA cm <sup>-2</sup>	32
MoP@Ni <sub>3</sub> P/NF	1 M KOH	1.67 V @ 10 mA cm <sup>-2</sup>	33



**Table S4.** Summary of electrochemical performance of transition metal oxide heteronanostructure reported in literature.

<b>Material</b>	<b>Fabrication method</b>	<b>Current Collector</b>	<b>Electrolyte</b>	<b>C, F g<sup>-1</sup> (Current density A g<sup>-1</sup>)</b>	<b>Stability (Cycles)</b>	<b>Ref.</b>
NiO@CuCo <sub>2</sub> O <sub>4</sub> /MoNi heterostructure	Hydrothermal/ ALD	NF	2 M KOH	3527.7 F g <sup>-1</sup> (1587.5 C g <sup>-1</sup> ) (1 A g <sup>-1</sup> )	84.2% (50000)	This work
Cu <sub>2</sub> O@Mn(OH) <sub>2</sub>	Solvent process	NF	2 M KOH	647.2 F g <sup>-1</sup> (0.5 A g <sup>-1</sup> )	71.5% (3000)	<sup>34</sup>
CuCo <sub>2</sub> O <sub>4</sub> /MnCo <sub>2</sub> O <sub>4</sub>	Hydrothermal	NF	2 M KOH	1434 F g <sup>-1</sup> (0.5 A g <sup>-1</sup> )	98.4% (5000)	<sup>35</sup>
CuCo <sub>2</sub> O <sub>4</sub> @Ni(OH) <sub>2</sub>	Hydrothermal and Electrodeposition	NF	6 M KOH	1902.0 F g <sup>-1</sup> (2 A g <sup>-1</sup> )	87.6% (50000)	<sup>36</sup>
CuCo <sub>2</sub> O <sub>4</sub> /NiMoO <sub>4</sub>	Hydrothermal	NF	3 M KOH	2215.0 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	98% (8000)	<sup>37</sup>

CoMoS@Co(OH) <sub>2</sub>	Hydrothermal and calcination	Carbon cloth	3M KOH	1711.0 F g <sup>-1</sup> (20 mA cm <sup>-2</sup> )	90.3% (5000)	38
CuCo <sub>2</sub> O <sub>4</sub> @Co(OH) <sub>2</sub>	Hydrothermal	NF	1 M KOH	375.0 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	85.8% (10000)	39
CuCo <sub>2</sub> O <sub>4</sub> /CuO nanowire	Hydrothermal	NF	2 M KOH	642.0 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	88% (5000)	40
NiO/NiCo <sub>2</sub> O <sub>4</sub> /Co <sub>3</sub> O <sub>4</sub>	sol-gel process and calcination	NF	2M KOH	1600.0 F g <sup>-1</sup> (2.5 A g <sup>-1</sup> )	94.9% (1000)	41
Co <sub>3</sub> O <sub>4</sub> @CoNi-LDH	Hydrothermal	NF	2M KOH	2676.9 F g <sup>-1</sup> (0.5 A g <sup>-1</sup> )	67.7% (10000)	42
CuCo <sub>2</sub> O <sub>4</sub> @Ni(OH) <sub>2</sub>	Hydrothermal and Chemical deposition	Carbon fiber cloth	2 M KOH	2160.0 F g <sup>-1</sup> (5 A g <sup>-1</sup> )	92% (5000)	43
CuCo <sub>2</sub> O <sub>4</sub> NWs@NiMoO <sub>4</sub>	Hydrothermal	NF	6 M KOH	2207.0 F g <sup>-1</sup> (1.25 A g <sup>-1</sup> )	95.6% (5000)	44
CuCo <sub>2</sub> O <sub>4</sub> /NiO nanotrees	Hydrothermal and	NF	1 M NaOH	2219.0 F g <sup>-1</sup>	95.3%	45

	Chemical bath deposition			(1 A g <sup>-1</sup> )	(10000)	
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**Table S5.** Comparison of energy storage performance of various Cu and Co-based HSCs.

HSC devices	Cell voltage (V)	Electrolyte	C <sub>s</sub> /F g <sup>-1</sup> (Current density A g <sup>-1</sup> )	Stability (Cycles)	Energy density (W h kg <sup>-1</sup> )	Power density (W kg <sup>-1</sup> )	Ref.
NiO@CuCo <sub>2</sub> O <sub>4</sub> /MoNi heterostructure//AC	1.6	KOH	226.7 F g <sup>-1</sup> (362.8 C g <sup>-1</sup> ) (1 A g <sup>-1</sup> )	90.4% (25000)	80.6	692.8	This work
CuCo <sub>2</sub> O <sub>4</sub> /CuO//RGO/Fe <sub>2</sub> O <sub>3</sub>	1.6	KOH	93.0 F g <sup>-1</sup> (0.25 A g <sup>-1</sup> )	83.0% (5000)	33.0	200.0	<sup>40</sup>
Co <sub>3</sub> O <sub>4</sub> @CoNi-LDH//AC	1.5	KOH	195.9 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	103.5% (5000)	61.2	750	<sup>42</sup>
CuCo <sub>2</sub> O <sub>4</sub> /MnCo <sub>2</sub> O <sub>4</sub> //graphene	1.6	KOH	118.4 F g <sup>-1</sup> (0.5 A g <sup>-1</sup> )	88.4% (10000)	42.1	400.0	<sup>35</sup>
CuCo <sub>2</sub> O <sub>4</sub> /NiMoO <sub>4</sub> //AC	1.5	KOH	~140.0 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	89% (5000)	44.8	374.2	<sup>37</sup>
CuCo <sub>2</sub> O <sub>4</sub> @NiMoO <sub>4</sub> //AC	1.6	KOH	128.2 F g <sup>-1</sup>	80.2 %	40.0	-	<sup>44</sup>

			(1 A g <sup>-1</sup> )	(5000)			
CNTs@NCDHNS//rGO-Fe <sub>2</sub> O <sub>3</sub>	1.6	KOH	108.7 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	~93.5% (1000)	54.6	1130.0	46
NiCo-LDH/NiMoS <sub>x</sub> // Fe <sub>2</sub> O <sub>3</sub> /rGO	1.6	KOH	203.9 F g <sup>-1</sup> (3 mA cm <sup>-2</sup> )	91.5% (10000)	72.6	522.7	47
CuCo <sub>2</sub> O <sub>4</sub> /NiO//AC	1.6	NaOH	155.0 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	91.5% (5000)	51.8	866.0	45
CuCo <sub>2</sub> O <sub>4</sub> @MnMoO <sub>4</sub> //graphene	1.6	KOH	165.7 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	92.5% (6000)	58.9	670.0	48
CuCo <sub>2</sub> O <sub>4</sub> @PPy//Carbon	1.4	KOH	208.0 F g <sup>-1</sup> (2 A g <sup>-1</sup> )	92 % (5000)	52.0	748.0	49
CuCo <sub>2</sub> O <sub>4</sub> @Ni(OH) <sub>2</sub> //AC	1.6	KOH	108.5 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	93.7% (5000)	38.6	800.0	36
CuCo <sub>2</sub> S <sub>4</sub> /CuCo <sub>2</sub> O <sub>4</sub> //graphene	1.6	KOH	90.4 F g <sup>-1</sup> (1 A g <sup>-1</sup> )	73.0% (5000)	33.2	800.0	50

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